

Übersicht der UV-Lampen und ihre Einsatzgebiete

Darmstadt, 15. Oktober 2009 Alex Voronov



GOAL

- to give an overview for existing UV-lamps
- and their application areas

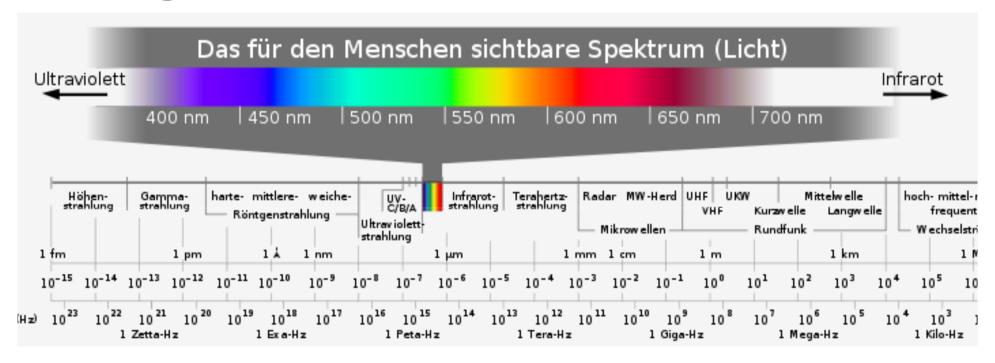


OUTLINE

- UV-Light
- UV-Light Sources based on Mercury Vapor Discharge
- Mercury free UV-Light Sources
- Application Areas



UV-Light

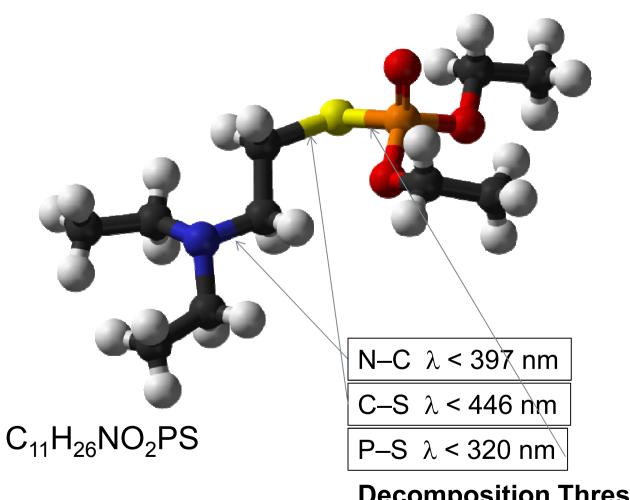


UV-A	315 – 380 nm	3.3 - 4.0 eV
UV-B	280 – 315 nm	4.0 - 4.4 eV
UV-C	200 – 280 nm	4.4 - 6.2 eV
V-UV	100 – 200 nm	6.2 - 12.4 eV

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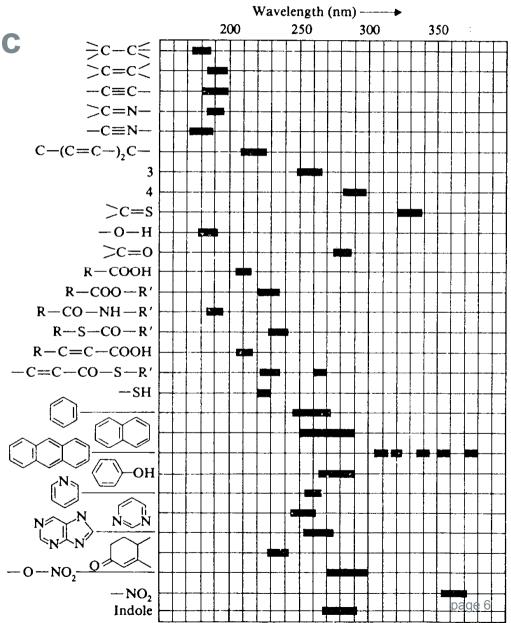
Photolysis of Organic Matter



Decomposition Threshold



Dissociation of Organic Bonds by UV-Light





Application Fields of UV-Light

UV-Light

Water/Air Treatment, Disinfection Surface Treatment, Modification Ink Curing in Printing Industry

Tanning, Medicine



UV-Light Sources

UV-Light

Low Pressure Mercury Lamps

Medium Pressure Mercury Lamps

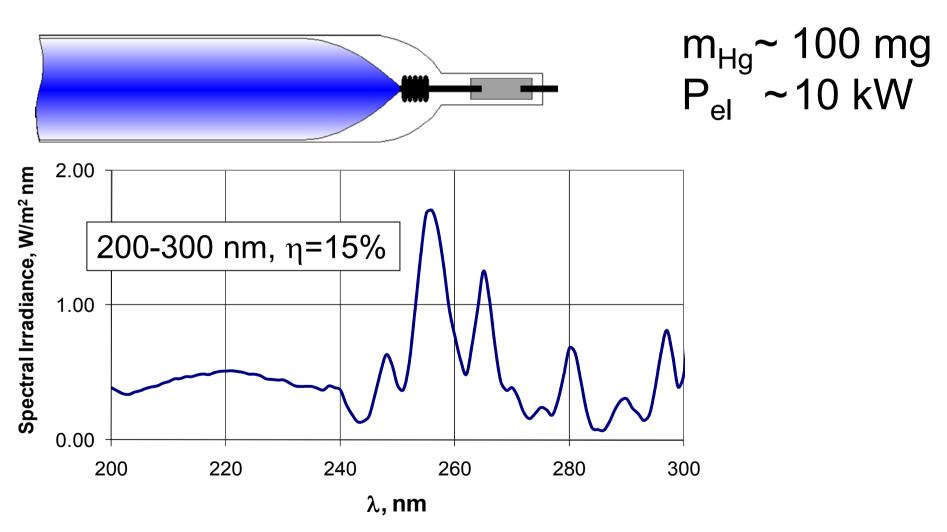
Excimer Lamps

Heraeus

Medium Pressure Lamps

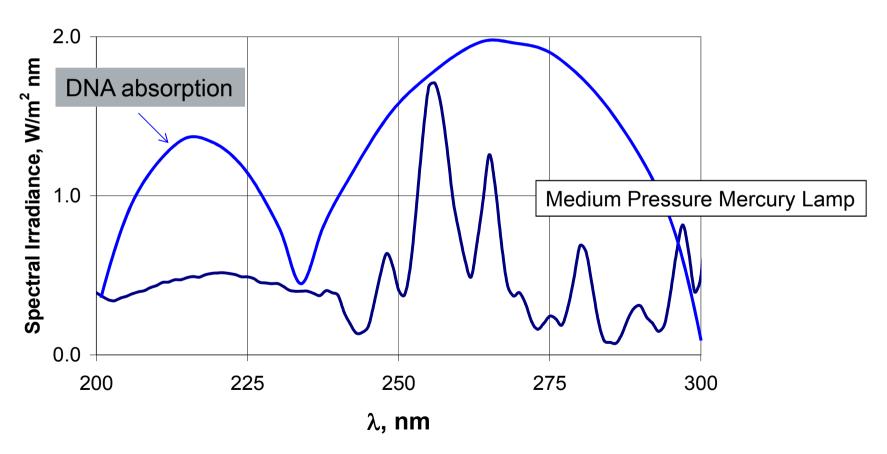


Medium Pressure Lamp



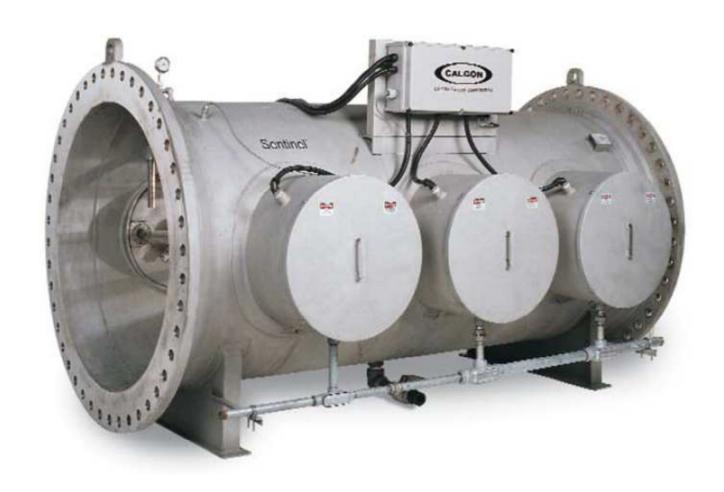


Spectrum of MP Lamp and DNA Absorption



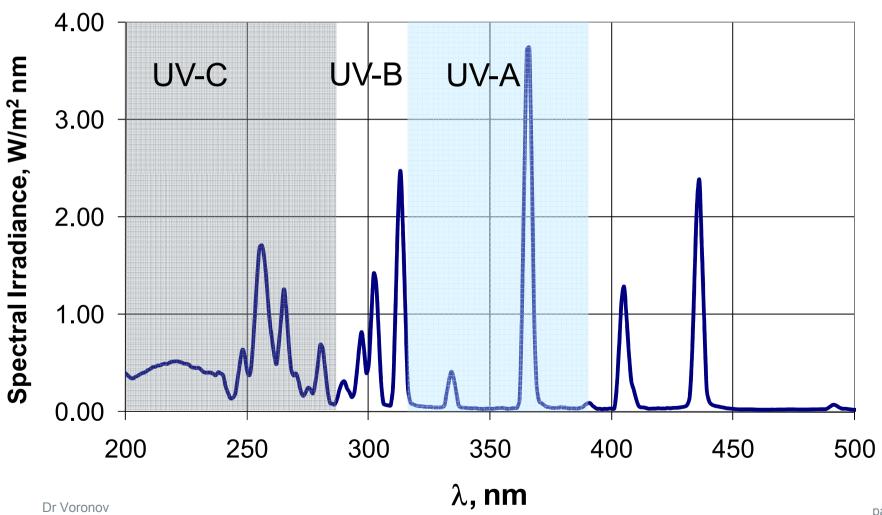


MP Lamps for Water Disinfection





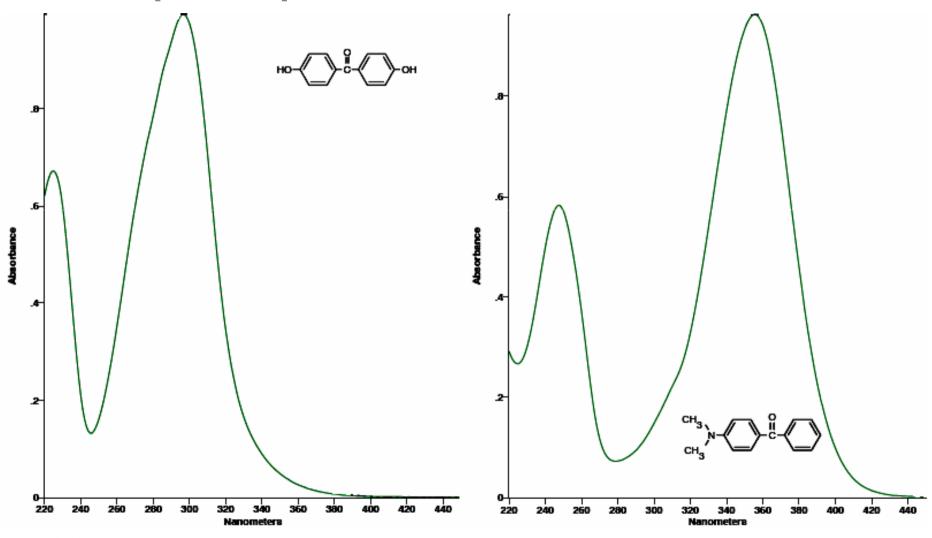
MP Lamps – Spectra in UV-A and UV-B Regions



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Absorption Spectra of Photoinitiators

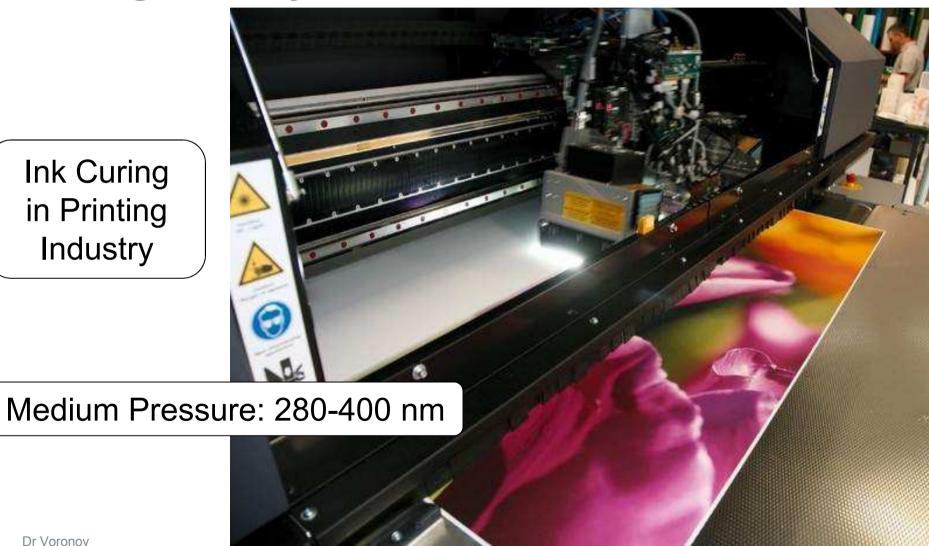


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Printing Industry

Ink Curing in Printing Industry



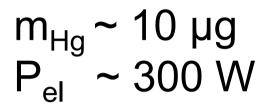
Heraeus

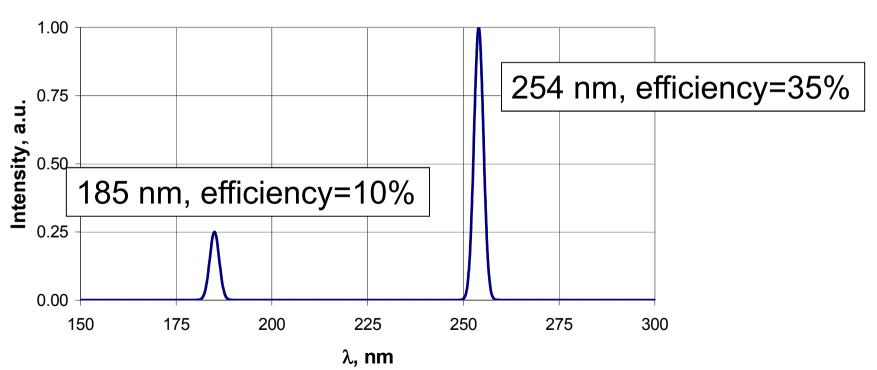
Low Pressure Lamps



Low Pressure Lamp

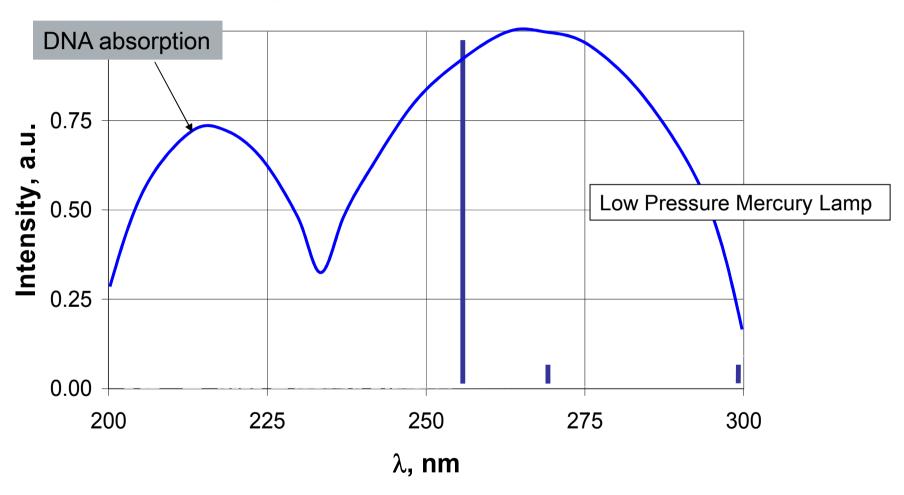






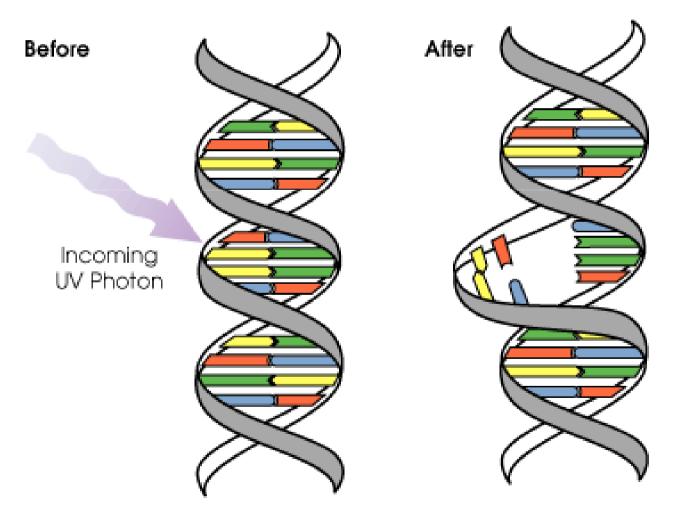


Spectrum of Hg-Lamps and DNA Absorption





DNA Destruction



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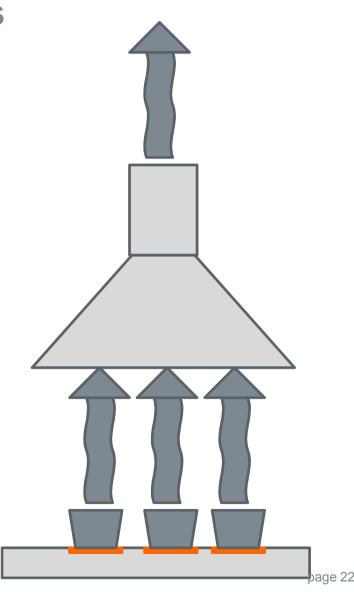
Water Disinfection



Heraeus

Air Treatment - Kitchen Hoods

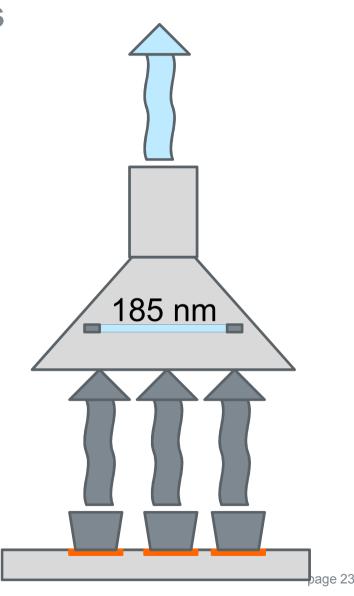




Heraeus

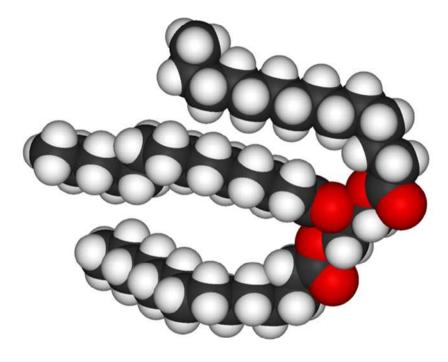
Air Treatment - Kitchen Hoods







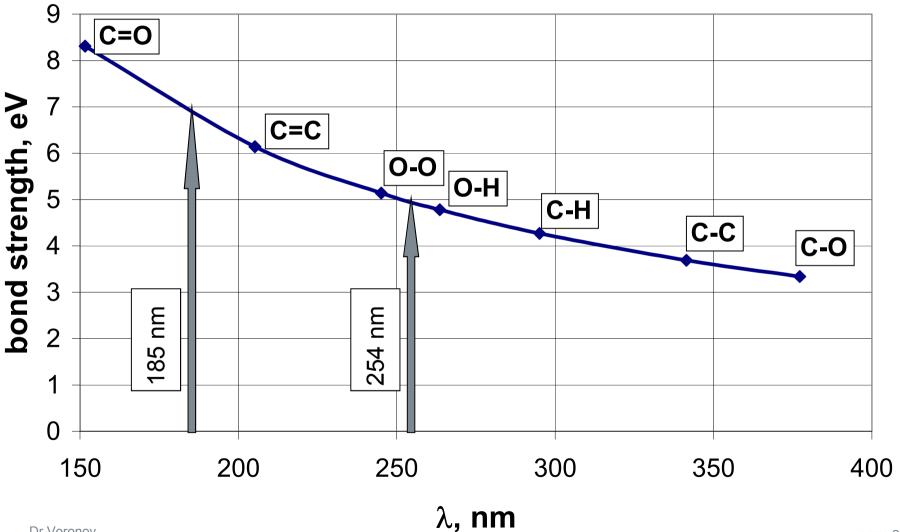
Molecular Structure of Fat



Decomposition Threshold

C-H λ < 293 nm C-O λ < 339 nm C=O λ < 162 nm 

Bond Strength vs. Photon Energy

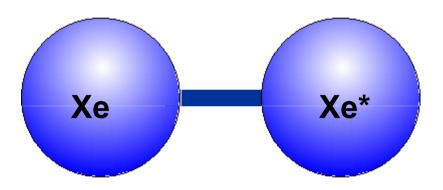




Xe₂* Excimer Lamp (172 nm)



Excimer Molecule

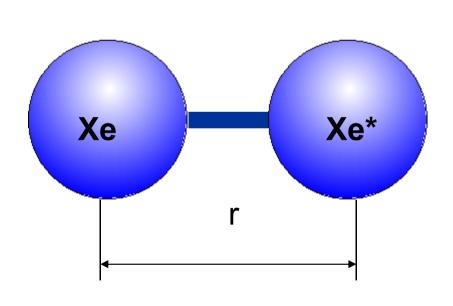


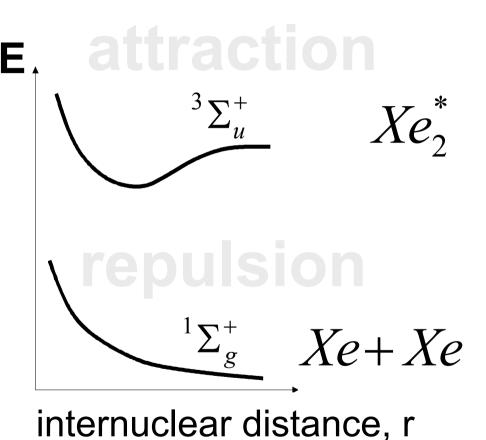
Excited Dimer

Life Time ~ ns



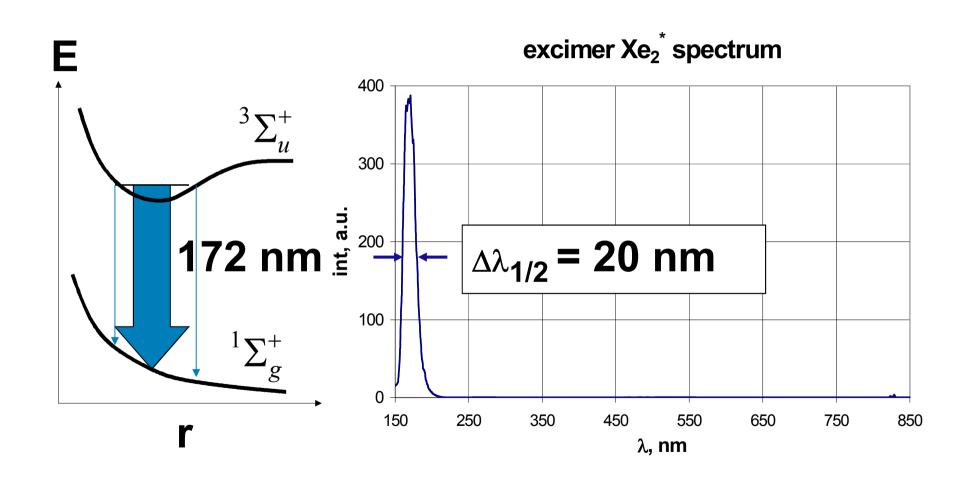
Excimer Molecule Xe₂*





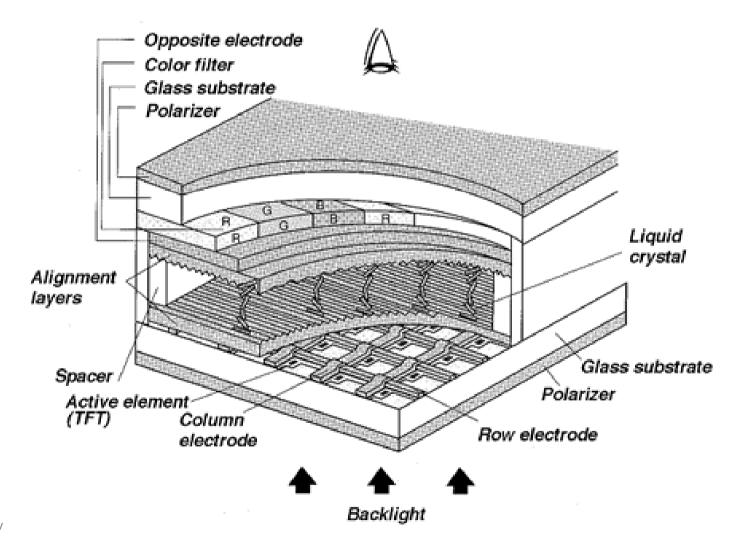


Emission at 172 nm



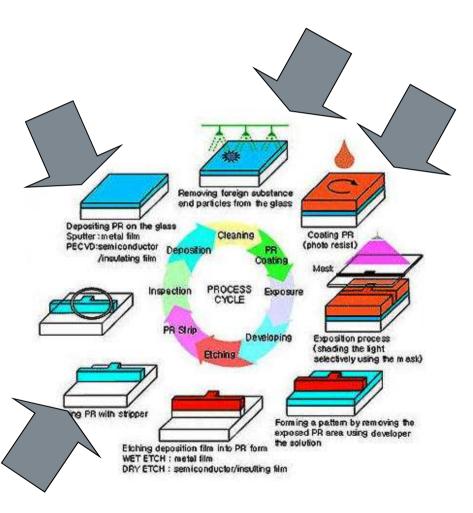


LCD Cross Section





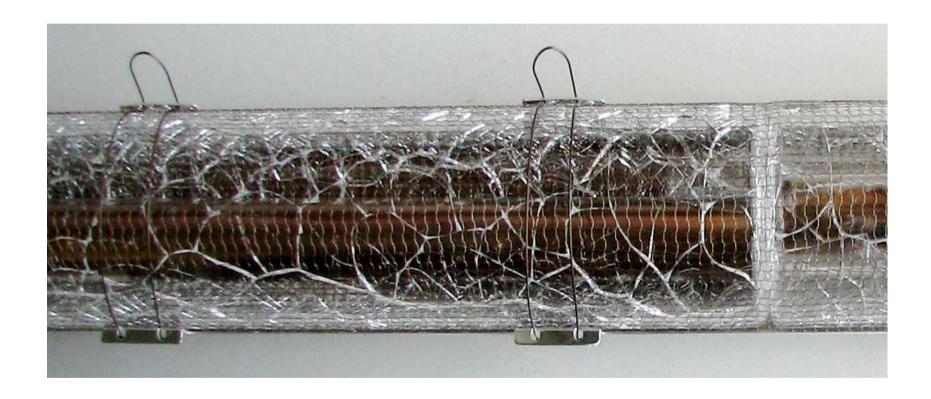
VUV-Light, λ =172 nm



- Removal of Cleaning Agents
- Surface Conditioning
- Polymer Removal



Quartz Destruction by Photons





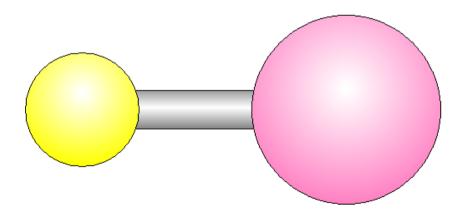
Excimer Lamps: Mercury Free UV-Light Sources

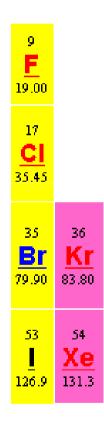


Excimer Molecule Rare Gas + Halogen

High Emission Efficiency Condition:

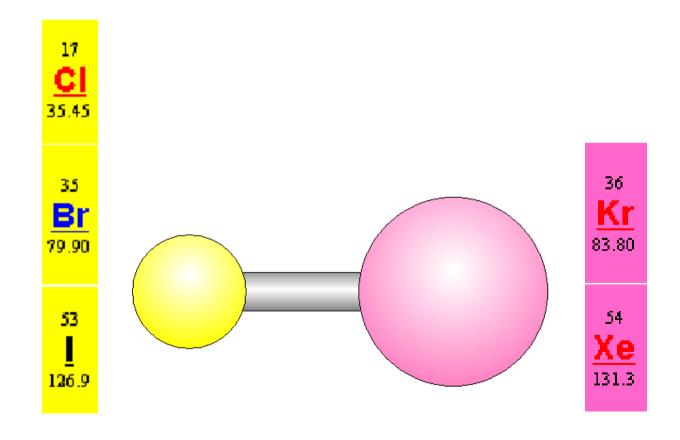
Light Halogen + Heavy Rare Gas Atom







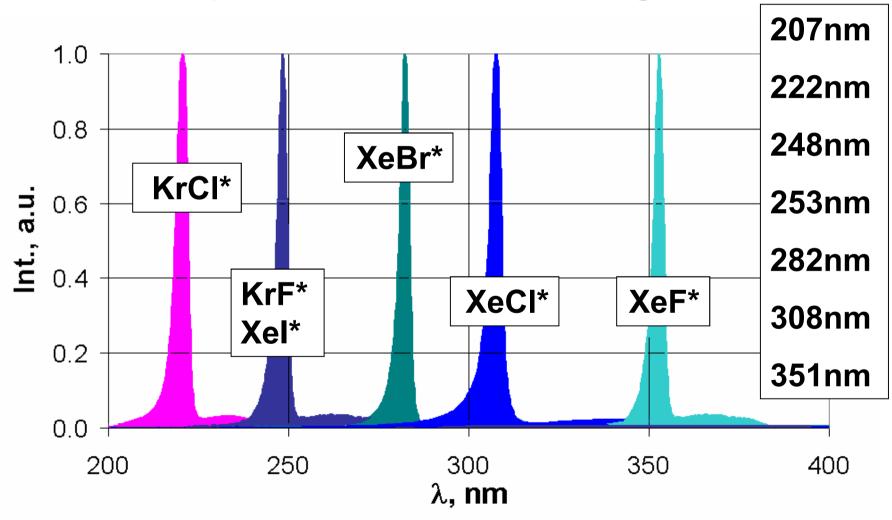
Excimer Molecule Rare Gas + Halogen



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Excimer Spectra: Rare Gas + Halogen





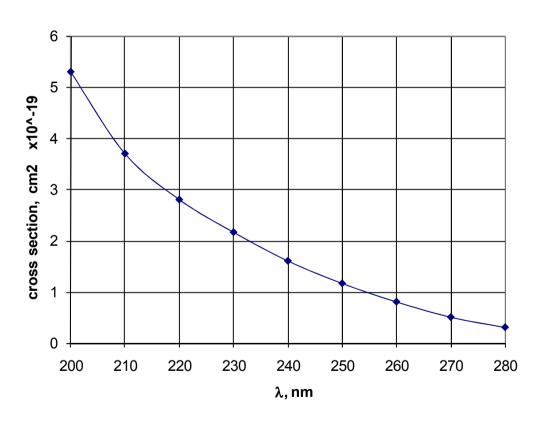
XeCI* (308 nm) for Treatment of Psoriasis





KrCl* (222 nm) for Surface Disinfection

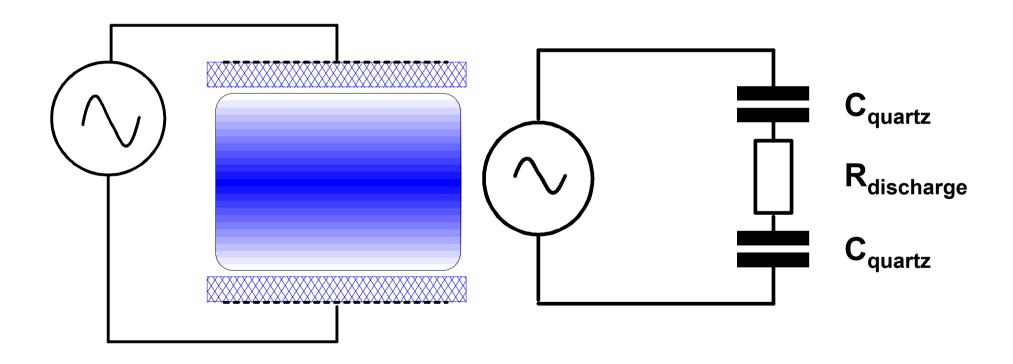
UV-absorption of H₂O₂



$$H_2O_2 + h\nu (222 \text{ nm}) \rightarrow 2 \bullet OH$$

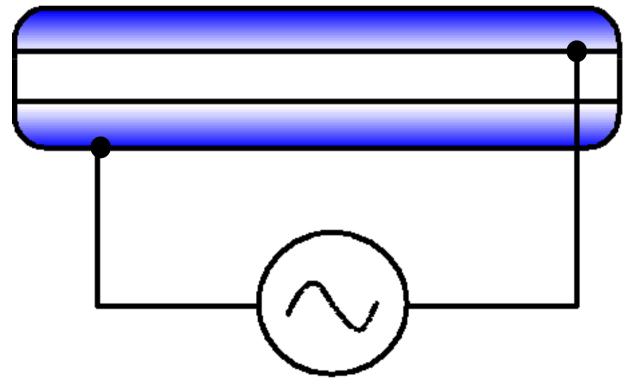


Barrier discharge lamp





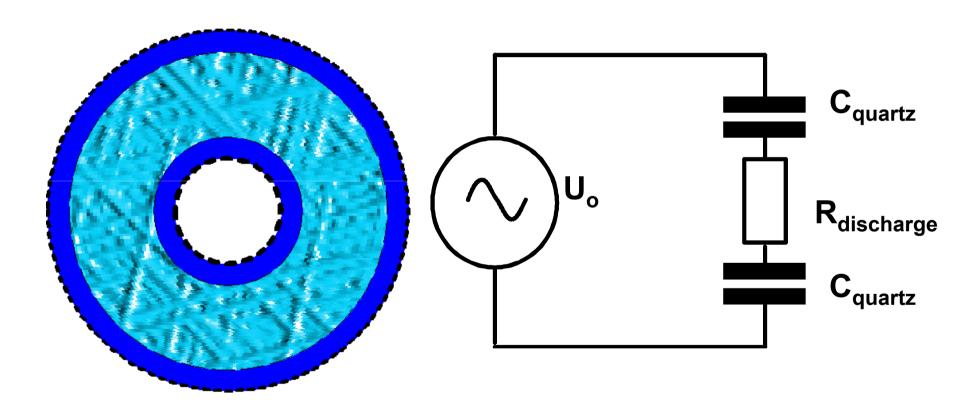
Dielectric Barrier Discharge



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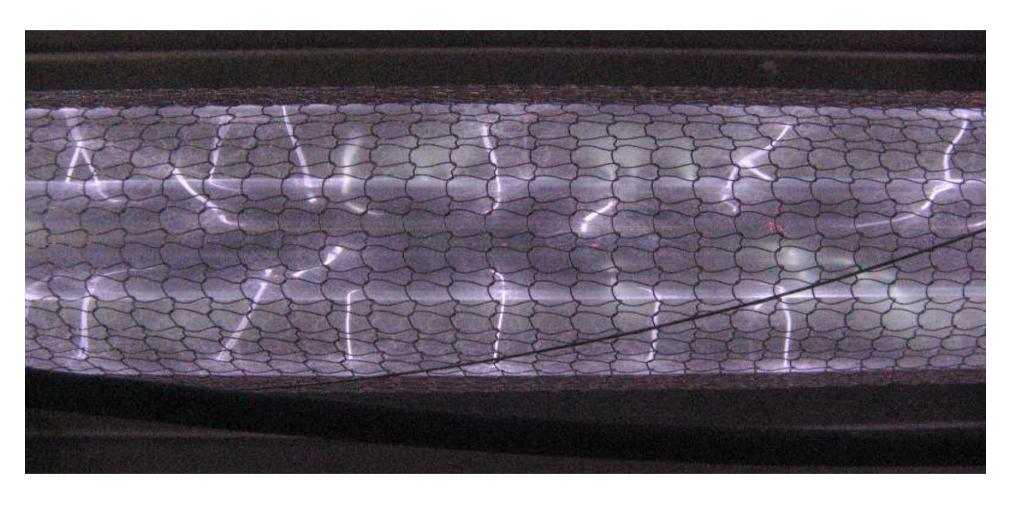
Barrier Discharge: Operation





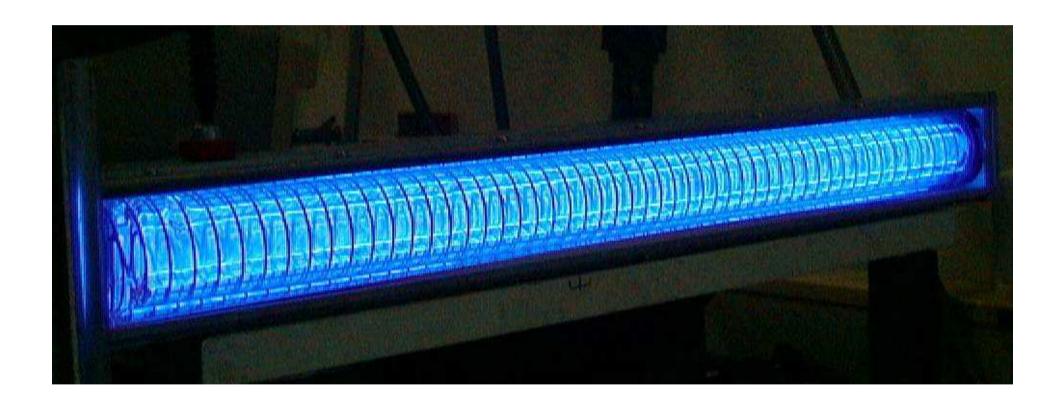


Mesh Electrode of DBD Lamp





Spiral Electrodes of a DBD Lamp





Conclusions



Application Areas of UV-Lamp

UV-Light

Water/Air Treatment, Disinfection Surface Treatment, Modification Ink Curing in Printing Industry

Tanning, Medicine

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S. Macritai, V.V., Ville

NR Mercury

S Mescrity Archive; South



Thank You for Your Attention!